In all investigations concerning pressure influence on superconductions $\frac{1}{2}$ main attention is given to the change of the critical temperature $T_{\rm c}$ and $r_{\rm c}$ magnetic field H_c [3]. In [4] it was considered that $2\,J/kT_c$ does not ck_c

One of the direct experimental methods for the study of the energy superconductors is the electron tunnelling technique. Possibilities of superconductors is the electron tunnelling technique. Possibilities of finest instrument allowed to find out a change of $2~A/kT_{\rm e}$ with pressure at

This paper presents results on tunnelling investigations of the energy g_{3} In and Tl under pressure.

2. Experimental Technique

2.1 Samples

As is known [7] the best gaps can be obtained on superconductor- $b_{art.}$ As is known [1] the best gaps can be obtained on superconductor—name superconductor tunnel systems. This made superconducting diodes useful superconductor tunner systems. This made superconducting diodes usemi-investigations under pressure. Of all systems investigated the best are parprepared on Al base, i.e. an Al-Al₂O₃ superconductor.

Al-I-In and Al-I-Tl samples were prepared by deposition in high (1 \times 10⁻⁶T. Vacuum on a cooled (up to 80 to 100 °K) glass slide 4×16 mm². There were three junctions on one slide, each $1_{Al} \times 0.5_{In,Tl}$ mm² (Fig. 1). To avoid elements effects films were deposited through stencils supported by an electromagnet Junction quality in the sense of fitness for their use in pressure measurement much depended on condensation and oxidation conditions of the Al fa-Aluminium was sprayed from a tungsten U-vaporizer. During deposition the vacuum did not become worse due to preliminary long annealing (up to vacuum vacuum one not become worse one to premininary iong annealing tup to vacuum restoration) of the vaporizer and the hinge. Oxidation took place in the atmosphere phere of dry air at a pressure of 0.2 Torr for 5 min. Sample preparation was controlled by film and junction resistance measurements both during deposits and subsequent heating up to room temperatures. Junctions with resistanand subsequent neating up to room temperatures. Junctions with resistant 50 to $100~\Omega$ were chosen. Al-I-Tl samples were covered with Si monoxide. 30 to 100 Ω were enosen. Al-1-11 samples were covered with 51 monoxide about 1 μm thickness. In and Tl film thickness was determined by Linnick about 1 μm thickness. In and 11 μm thickness was determined by Limbers microinterferometer MH-4 and was equal to (1000 \pm 100) A. For Tl films

All films had resistivities of 4000 to 6400 Ω mm², and their initial critical temperature varied from 1.65 to 2 °K.

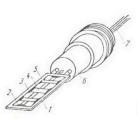


Fig. 1. Tunnel sample and obturator, 1 Sample holder made getinax, 2 indium contacts, 3 Al film, 4 In and TI films, 5 cover glass, 6 obturator, 7 electrical wires

Effect of High Pressure on the Energy Gap of Indium and Thallium

2.2 High pressure technique

thigh pressure bomb with kerosene-oil mixture [8] was used in all investi-Pressure was created at room temperature and controlled by a hydraulic . He manometer. Here an almost linear change of tunnel junction resistance $_{\rm Tor} R(0) = 100 \ \Omega, \ {\rm d}R/{\rm d}p = 6 \ \Omega/{\rm katm})$ was a reliable indication. Sensitiof junction resistance to pressures gave the possibility of rejecting samples remmersing into liquid helium. The final pressure in the bomb at low peratures was calculated from Tc changes of an In wire [9]:

$$T_{\rm c} = 4.36\!\times\!10^{-5}~p\,+\,5.2\!\times\!10^{-10}~p^{\rm 2}\,.$$

dectrical conductors were introduced into the obturator, this allowed meaements to be carried out simultaneously, by means of a 4-probe system, the critical temperature of films, the In wire, and corresponding tunnel aracteristics.

2.3 Cryogenics and measuring apparatus

how temperature measurements were carried out in a metal cryostat where $_{\rm 2.18}$ possible to get temperatures from 4.2 to 1.15 °K. The bomb with samples in liquid helium.

buring the experiments the voltage-current characteristic was measured both constant voltage and constant current conditions. Depending on the conon $\mathrm{d}I/\mathrm{d}U$ or $(\mathrm{d}U/\mathrm{d}I)-U$ at a modulation frequency of 383 Hz were plotted. Ill tunnel characteristics were recorded automatically on a X-Y coordinate 1.09-type register. Constant voltage at a sample was measured by a highmic potentiometer to within $\approx 1 \,\mu\text{V}$ during recording.

3. Results and Discussion

Indium: After preparation Al-I-In samples were annealed for some days room temperature. The critical temperature of In films practically did not Her from $T_{\rm e}$ for massive pure indium. The halfwidth of the superconducting metion did not exceed 0.01 °K for all pressures. Table 1 gives the change of ntical temperature for the film which is found to be

$$rac{{
m d}T_{
m c}}{{
m d}p} = \, - \, (3.65 \pm 0.15)\! imes\!10^{-5} \, rac{{
m ^o K}}{{
m atm}} \, ,$$

Table 1 $T_{\rm c}$ and 2 \varDelta of indium under pressure

p katm)	$(\mp 0.01 {}^{\circ}{ m K})$	$t = \frac{T}{T_{\rm c}}$	$(\mp 0.01 \text{ meV})$	$2 \Delta/kT_{ m c} ^{ m C} \ (p,t)$	2 A(p, 0) (meV)	$2 \Delta/kT_{\rm c}$ $(p, 0)$
0 5 7 7.9 10.5	3.42 3.23 3.15 3.13 3.03 2.91	0.342 0.36 0.372 0.374 0.387 0.4	1.090 1.01 0.982 0.974 0.930 0.880	3.69 3.63 3.62 3.61 3.57 3.51	1.09 1.02 0.99 0.98 0.94 0.89	3.69 3.66 3.64 3.64 3.60 3.55